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## In the Claims:

- 13. (Original) A phase-change memory comprising:
- a first electrode contact;
- a phase-change layer on the first electrode contact; and
- a second electrode contact on the phase-change layer, wherein a set state is a state in which amorphous nuclei are formed in the phase-change layer that has a set resistance of from about 4 k $\Omega$  to 6 k $\Omega$ , and a reset state is a state in which the number and density of the amorphous nuclei are greater than in the set state and has a reset resistance of about 6 k $\Omega$  to 20 k $\Omega$ .
- 14. (Previously Presented) The phase-change memory of Claim 13, wherein a current for writing the reset state and/or the set state on the phase-change layer is from about  $10~\mu A$  to about  $200~\mu A$ , and a period required for writing the reset state and/or the set state from the phase-change layer is from about 10 nanoseconds to about 100 nanoseconds.
- 15. (Previously Presented) The phase-change memory of Claim 13, wherein a current for writing the set state in the phase-change layer is from about 30  $\mu$ A to about 50  $\mu$ A, and a current for writing the reset state in the phase-change layer is from about 60  $\mu$ A to about 200  $\mu$ A.
- 16. (Previously Presented) The phase-change memory of Claim 13, wherein a diameter of the first electrode contact to which the current is applied to write the reset and set states in the phase-change layer is from about 40 nanometers to about 70 nanometers.
- 17. (Previously Presented) The phase-change memory of Claim 13, wherein a rising time and a falling time for writing the reset state and/or the set state in the phase-change layer is from about 1 nanosecond to about 4 nanoseconds.
- 18. (Previously Presented) The phase-change memory of Claim 13, wherein a current for reading the reset state and/or the set state is from about 3  $\mu$ A to about 6  $\mu$ A, and

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a time required for reading the reset state and/or the set state is from about 5 nanoseconds to about 10 nanoseconds.

- 19. (Currently Amended) The phase-change memory of Claim 14, wherein a current for reading the reset state and/or the set state [iss] is from about 3  $\mu$ A to about 6  $\mu$ A, and a time required for reading the reset state and/or the set state is from 5 nanoseconds to about 10 nanoseconds.
  - 26. (Original) A phase change memory, comprising:

first and second electrode contacts;

- a phase-change layer between the first and second electrode contacts, the phase change layer providing a first state established by a first number of amorphous nuclei in a crystalline matrix in a region adjacent an interface between the phase-change layer and the first electrode.
- 27. (Original) The phase change memory of Claim 26, wherein the phase change layer further provides a second state established by a second number of amorphous nuclei in a crystalline matrix in the region adjacent the interface between the phase-change layer and the first electrode, the second number being greater than the first number.
- 28. (Original) The phase change memory of Claim 27, wherein the first number of amorphous nuclei and the second number of amorphous nuclei provide a ratio of resistances of the phase-change layer of from about 1.5 to about 3.
- 29. (Previously Presented) The phase change memory of Claim 27, wherein the first state of the phase-change layer provides a resistance of the phase-change layer of from about 4 to about 6 k $\Omega$  and the second state the phase-change layer provides a resistance of the phase-change layer of from about 6 to about 20 k $\Omega$ .
- 30. (Previously Presented) The phase change memory of Claim 27, wherein a current for writing the first state or the second state on the phase-change layer is from about

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 $10 \mu A$  to about  $200 \mu A$ , and a period required for writing the first state or the second state from the phase-change layer is from about 10 nanoseconds to about 100 nanoseconds.

- 31. (Previously Presented) The phase change memory of Claim 27, wherein a current required for writing the first state in the phase-change layer is from about 30  $\mu$ A to about 50  $\mu$ A, and a current required for writing the second state in the phase-change layer is from about 60  $\mu$ A to about 200  $\mu$ A.
- 32. (Previously Presented) The phase change memory of Claim 27, wherein a diameter of the first electrode contact to which a current is applied to write the first and second states in the phase-change layer is from about 40 nanometers to about 70 nanometers.
- 33. (Previously Presented) The phase change memory of Claim 27, wherein a current for reading the first state and/or the second state is from about 3  $\mu$ A to about 6  $\mu$ A, and a time required for reading the first state and/or the second state is from about 5 nanoseconds to about 10 nanoseconds.
- 34. (Original) A method of operating a phase change memory, comprising: establishing logic states in a phase change memory by controlling amorphous nucleation in a crystalline matrix of a phase-changeable material.
- 35. (Currently Amended) The method of Claim 34, wherein a first logic state is established by a first number of amorphous nuclei in the crystalline matrix and a second logic state is established by a second number of amorphous nuclei in the crystalline matrix in the, the second number being greater than the first number.
- 36. (Original) The method of Claim 35, wherein the first number of amorphous nuclei and the second number of amorphous nuclei provide a ratio of resistances of the phase-changeable material of from about 1.5 to about 3.

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- 37. (Original) The method of Claim 35, wherein the first logic state provides a resistance of the phase-change layer of from about 4 k $\Omega$  to about 6 k $\Omega$  and the second logic state provides a resistance of the phase-change layer of from about 6 k $\Omega$  to about 20 k $\Omega$ .
- 38. (Original) The method of Claim 35, wherein controlling amorphous nucleation comprises controlling a current for writing the first logic state or the second logic state to be from about 10  $\mu$ A to about 200  $\mu$ A, and a period required for writing the first logic state or the second logic state to be from about 10 nanoseconds to about 100 nanoseconds.
- 39. (Original) The method of Claim 35, wherein controlling amorphous nucleation comprises:

controlling a current for writing the first logic state to be from about 30  $\mu A$  to about 50  $\mu A$ ; and

controlling a current or writing the second logic state to be from about 60  $\mu A$  to about 200  $\mu A$ .

- 40. (Original) The method of Claim 35, wherein a diameter of the first electrode contact to which a current is applied to write the first and second logic states is from about 40 nanometers to about 70 nanometers.
- 41. (Original) The method of Claim 35, further comprising controlling a current for reading the first logic state and/or the second logic state to be from about 3  $\mu$ A to about 6  $\mu$ A, and a time for reading the first state and/or the second state to be from about 5 nanoseconds to about 10 nanoseconds